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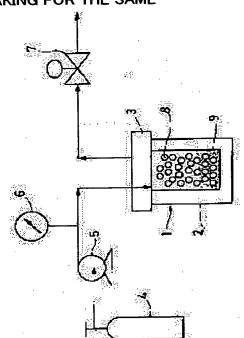
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(54) SLOW-RELEASING MATERIAL AND METHOD OF MAKING FOR THE SAME

(57)Abstract:

PROBLEM TO BE SOLVED: To provide a slow-releasing material which performs effectively disposition of the component on porous materials by a simple operation with a few processes without using solvents such as organic solvents, polluting the environment and has persistence of absorber aromatic or deodorant components, medicinal components, mothproof or insecticidal components and other components on the porous materials such as wooden materials, organic polymeric materials such as plastics, inorganic materials such as ceramics and glasses, and to provide a method of making such a slow-releasing material.

SOLUTION: The slow-releasing material is obtained by observing the slow- release components into the pores of the porous materials using supertrictical or subcritical fluid as a medium. The method of making the slowreleasing material as achieved by bringing the supertrictical or subcritical fluid into contact with the porous materials and slow-release componentcontaining raw materials.



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